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	Application No.	Applicant(s)	_
Notice of Allowability	10/087,493	RUSHFORD, MICHAEL C.	
	Examiner	Art Unit	
	Roberts Culbert	1763	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate commits application is a sand MPEP 1308.	n this application. If not included unication will be mailed in due course. THIS	ve
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2. The allowed claim(s) is/are <u>1,2,4,8-10,15,17-20,22-27,31-</u>			
3. The drawings filed on 28 February 2002 are accepted by t	he Examiner.		
 4. ☐ Acknowledgment is made of a claim for foreign priority unallocation. a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 	e been received.		
2. Certified copies of the priority documents have			
3. Copies of the certified copies of the priority do	cuments have been receive	d in this national stage application from the	
International Bureau (PCT Rule 17.2(a)). * Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file IENT of this application.	a reply complying with the requirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EX es reason(s) why the oath o	AMINER'S AMENDMENT or NOTICE OF r declaration is deficient.	
6. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) including changes required by the Notice of Draftspers		w (PTO-948) attached·	
1) hereto or 2) to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or	r in the Office action of	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on t he header according to 37 CF	ne drawings in the front (not the back) of R 1.121(d).	
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	SIT OF BIOLOGICAL MATI FOR THE DEPOSIT OF BIO	ERIAL must be submitted. Note the DLOGICAL MATERIAL.	
Attachment(s)			
1. Notice of References Cited (PTO-892)		formal Patent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ∐ Interview Si Paper No./	ummary (PTO-413), Mail Date	
 Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 	8), 7. ⊠ Examiner's	Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit		Statement of Reasons for Allowance	
of Biological Material	9. 🗌 Other	_	
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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with James S. Tak on 3/31/05.

1. The application has been amended as follows:

Amend the status identifier of Claim 23 from (withdrawn) to (original). The claim has been considered by the examiner and is allowed as recited below.

2. Cancel claims 7, 21, 30 and 34-65

3. Amend Claim 1 to read as follows:

A method of figuring a substrate surface comprising the steps of:

contacting the substrate surface with an etchant solution, wherein an etch rate of the etchant solution increases with temperature; and

independently controlling the generation of a local thermal gradient in each of a plurality of selected local regions of a boundary layer of the etchant solution independent of other selected local regions, to imagewise etch the substrate surface in a parallel process.

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 3/16/05 has been entered.

Allowable Subject Matter

Claims 1, 2, 4, 8-10, 15, 17, 18-20, 22-27, 31-33 and 66-73 are allowed.

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The following is an examiner's statement of reasons for allowance: The prior art of record fails to teach or render obvious a method of figuring a substrate surface comprising the steps of contacting the substrate surface with an etchant solution, wherein an etch rate of the etchant solution increases with temperature; and independently controlling the generation of a local thermal gradient in each of a plurality of selected local regions of a boundary layer of the etchant solution independent of other selected local regions, to imagewise etch the substrate surface in a parallel process.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Roberts Culbert whose telephone number is (571) 272-1433. The examiner can normally be reached on Monday-Friday (8:30-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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